

International Trade Administration, U.S. Department of Commerce, 14th Street and Constitution Avenue, NW, Washington DC 20230; telephone (202) 482-3434 and (202) 482-0159, respectively.

SUPPLEMENTARY INFORMATION:

Background

On July 31, 1991, the Department issued an antidumping duty order on silicon metal from Brazil. *See Antidumping Duty Order: Silicon Metal from Brazil*, 56 FR 36135 (July 31, 1991) (*Antidumping Duty Order*). On September 5, 1996, the Department published its final results of the second administrative review of silicon metal for four Brazilian exporters, Companhia Brasileira Carbureto de Calcio ("CBCC"), Companhia Ferroligas Minas Gerais-Minasligas ("Minasligas"), Eletrosilex Belo Horizonte ("Eletrosilex"), Rima Eletrometalurgia S.A. ("Rima"). *See Silicon Metal from Brazil; Final Results of Antidumping Administrative Review*, 61 FR 46763 (September 5, 1996) (*Final Results*). On September 9, 1997, the Department published amended final results to correct ministerial errors raised by the parties after requesting and receiving from the CIT authority to do so. *See Silicon Metal from Brazil: Amended Final Results of Antidumping Duty Administrative Review* 62 FR 47441 (September 9, 1997) (*Amended Final Results*).

On July 30, 1998, the CIT issued an order, *American Silicon Technologies v. United States*, 19 F. Supp. 2d 1121 (CIT 1998), remanding to the Department the *Amended Final Results*. In its July 30, 1998 order, the CIT instructed the Department to ensure that any reduction of reported interest expenses for CBCC and Eletrosilex is based upon income specifically derived from short-term investments. *Id.*, at 1123.

On December 16, 1998, the Department filed its final results pursuant to remand. *See Final Results of Redetermination Pursuant to Court Remand, American Silicon Technologies, Elkem Metals Company, Globe Metallurgical, Inc. and SKW Metals & Alloys, Inc. v. United States* (December 16, 1998). On February 17, 1999, the CIT upheld the Department's redetermination on remand. *See American Silicon Technologies, Elkem Metals Company, Globe Metallurgical, Inc. and SKW Metals & Alloys, Inc. v. United States*, __CIT__, Slip Op. 99-17, (February 17, 1999). Neither party appealed the CIT's decision.

Because neither party appealed, there is now a final and conclusive court

decision in this action. We are therefore amending our final results of review for the period July 1, 1992 through June 30, 1993. We recalculated margins for CBCC and Eletrosilex. The revised weighted average margins are as follows:

Manufacturer/Exporter	Margin (percent)
CBCC	35.43
Eletrosilex	51.84

Accordingly, the Department will determine, and the Customs Service will assess, antidumping duties on all entries of subject merchandise from CBCC and Eletrosilex in accordance with these amended final results. For assessment purposes, we have calculated importer-specific duty assessment rates for each class or kind of merchandise based on the ratio of the total amount of antidumping duties calculated for the examined sales to the total quantity of sales examined. The Department will issue appraisement instructions directly to Customs. The above rate will not affect CBCC or Eletrosilex's cash deposit rates currently in effect, which continue to be based on the margins found to exist in the most recently completed review.

This notice is published in accordance with section 751(a)(1) of the Tariff Act (19 U.S.C. 1675(a)(1)) and 19 CFR 351.221.

Dated: May 15, 2000.

Troy H. Cribb,

Acting Assistant Secretary for Import Administration.

[FR Doc. 00-12980 Filed 5-22-00; 8:45 am]

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DEPARTMENT OF COMMERCE

International Trade Administration

University of Wisconsin-Milwaukee; Notice of Decision on Application for Duty-Free Entry of Scientific Instrument

This decision is made pursuant to section 6(c) of the Educational, Scientific, and Cultural Materials Importation Act of 1966 (Pub. L. 89-651, 80 Stat. 897; 15 CFR part 301). Related records can be viewed between 8:30 a.m. and 5:00 p.m. in Room 4211, Department of Commerce, 14th and Constitution Avenue, NW., Washington, DC.

Docket Number: 00-007.

Applicant: University of Wisconsin-Milwaukee, Milwaukee, WI 53211.

Instrument: Scanning Tunneling Microscope, Model STM 25DH.

Manufacturer: Omicron Vakuumphysik GmbH, Germany.

Intended Use: See notice at 65 FR 21397.

Comments: None received.

Decision: Approved. No instrument of equivalent scientific value to the foreign instrument, for such purposes as it is intended to be used, is being manufactured in the United States. Reasons: The foreign instrument provides:

(1) Capability to operate at temperatures to 1500° K, (2) a vibrationally isolated vacuum chamber capable to 10⁻¹¹ mbar and (3) vertical imaging of film surfaces with accuracy to 0.001 nm. The National Institute of Standards and Technology and a university research center for advanced microstructure devices advise that (1) these capabilities are pertinent to the applicant's intended purpose and (2) they know of no domestic instrument or apparatus of equivalent scientific value to the foreign instrument for the applicant's intended use (comparable case).

We know of no other instrument or apparatus of equivalent scientific value to the foreign instrument which is being manufactured in the United States.

Dated: May 16, 2000.

Frank W. Creel,

Director, Statutory Import Programs Staff.

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DEPARTMENT OF COMMERCE

National Oceanic and Atmospheric Administration

[I.D. 051800B]

At-sea Scale Certification Program

AGENCY: National Oceanic and Atmospheric Administration.

ACTION: Proposed collection; comment request.

SUMMARY: The Department of Commerce, as part of its continuing effort to reduce paperwork and respondent burden, invites the general public and other Federal agencies to take this opportunity to comment on proposed and/or continuing information collections, as required by the Paperwork Reduction Act of 1995, Public Law 104-13 (44 U.S.C. 3506(c)(2)(A)).

DATES: Written comments must be submitted on or before July 24, 2000.

ADDRESSES: Direct all written comments to Linda Engelmeier, Departmental Forms Clearance Officer, Department of